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| Form 1449 (Modified) Information Disclosure Statement By Applicant (Use Several Sheets if Necessary) | Atty Docket No. | BRIDP003 |
| | Application No.: | 09/724,839 |
| | Applicant | Schubert et al. |
| | Filing Date | 11/28/00 |
| | Group | 2824 |

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U.S. Patent Documents

| Examiner Initial | No. | Patent No. | Date | Patentee | Class | Sub-class | Filing Date |
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| | E. | | | | | | |
| | F. | | | | | | |
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| | H. | | | | | | |
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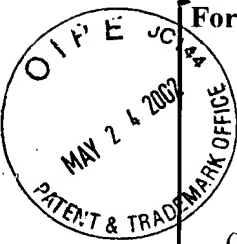
Foreign Patent or Published Foreign Patent Application

| Examiner Initial | | Document No. | Publication Date | Country or Patent Office | Class | Sub-Class | Translation | |
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| | | | | | | | Yes | No |
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Other Documents

| Examiner Initial | No. | Author, Title, Place (e.g. Journal) of Publication, Date |
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| | O. | |
| | P. | |
| | Q. | |
| Examiner | Yolanda Wilson | |
| | Date Considered | 10/29/03 |

Examiner: Initial citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.



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Other Documents

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